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EECS251B : Advanced Digital Circuits and Systems



Lecture 10 – Transistor Models

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Feb. 15, 2022, Reuters

Intel to acquire Tower Semiconductor in \$5.4 bln deal

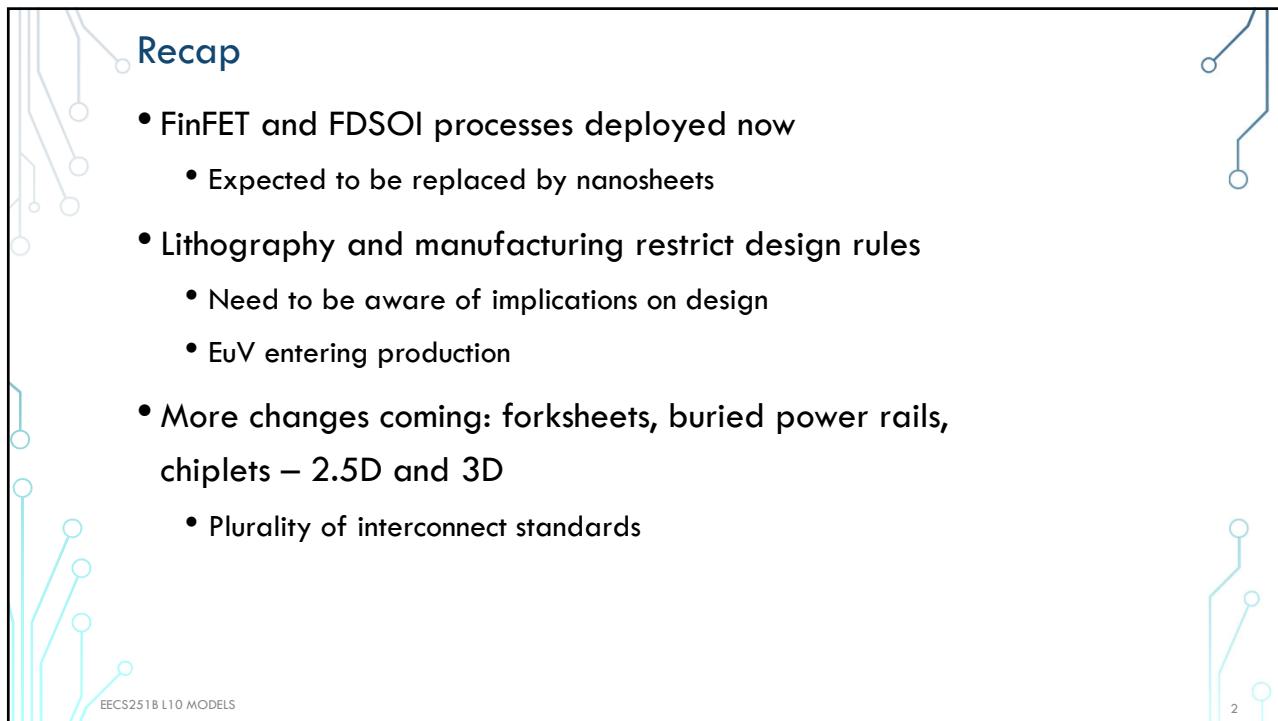
Intel Corp agreed to acquire Tower Semiconductor Ltd (TSEM.TA) for an enterprise value of \$5.4 billion, the companies said on Tuesday.

Intel will acquire Tower for \$53 per share in cash, the statement added.

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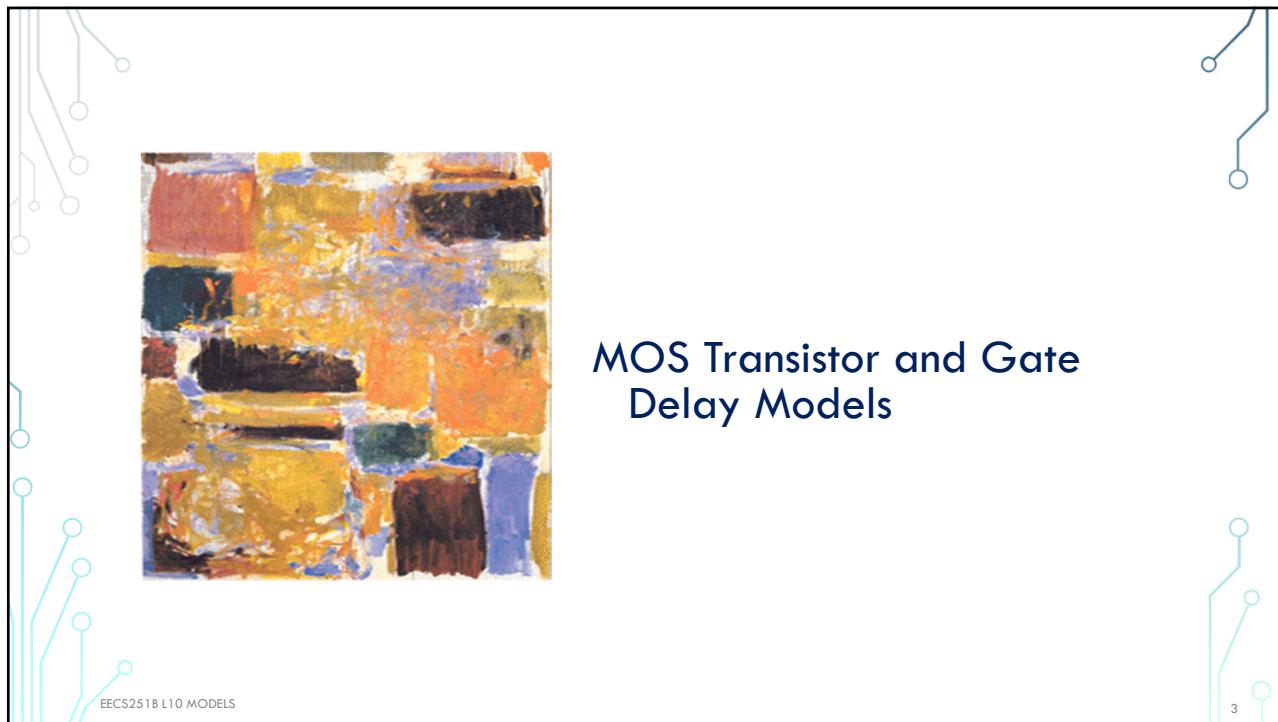


Recap

- FinFET and FDSOI processes deployed now
 - Expected to be replaced by nanosheets
- Lithography and manufacturing restrict design rules
 - Need to be aware of implications on design
 - EUV entering production
- More changes coming: forksheets, buried power rails, chiplets – 2.5D and 3D
 - Plurality of interconnect standards

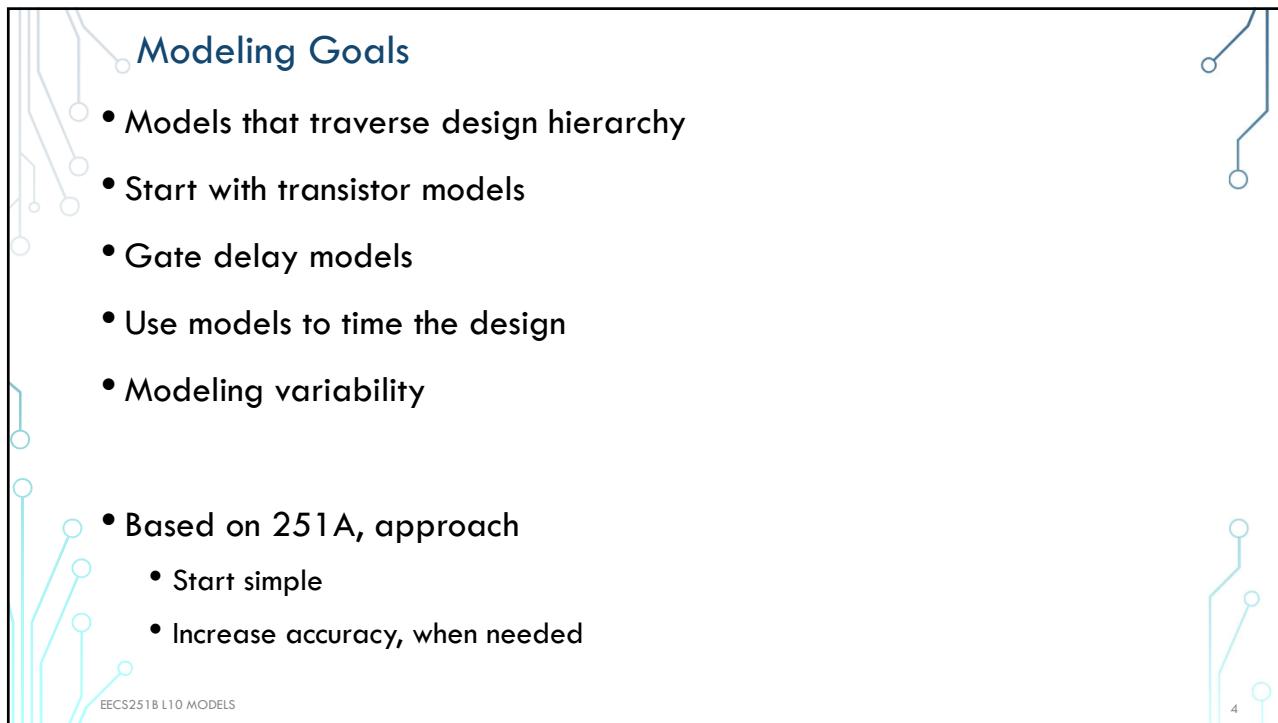
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MOS Transistor and Gate Delay Models

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Device Models

- Transistor models
 - I-V characteristics
 - C-V characteristics
- Interconnect models
 - R, C, L
 - Covered in EE240A

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Transistor Modeling

- Different levels:
 - Hand analysis
 - Computer-aided analysis (e.g. Matlab, Python, Excel,...)
 - Switch-level simulation (some flavors of 'fast Spice')
 - Circuit simulation (Hspice)
- These levels have different requirements in complexity, accuracy and speed of computation
- We are primarily interested in delay and energy modeling, rather than current modeling
- But we have to start from the currents...

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Transistor Modeling

- DC
 - Accurate I-V equations
 - Well behaved conductance for convergence (not necessarily accurate)
- Transient
 - Accurate I-V and Q-V equations
 - Accurate first derivatives for convergence
 - Conductance, as in DC
- Physical vs. empirical

from BSIM group

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Goal for Today

- Develop velocity-saturated model for I_{on} and apply it to sizing and delay calculation
 - Similar approach as in 251A, just use an analytical model

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Transistor I-V Modeling

- BSIM
 - Superthreshold and subthreshold models
 - Need smoothening between two regions
- EKV/PSP
 - One continuous model based on channel surface potential

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Announcements

- Assignment 1 posted this week
 - No new lab this week
- Project proposals due next Thursday
- No class on Tuesday

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Project proposals

- Title: Pick a meaningful title
- Authors, contact e-mail
- 1/2-page abstract
- 5 references

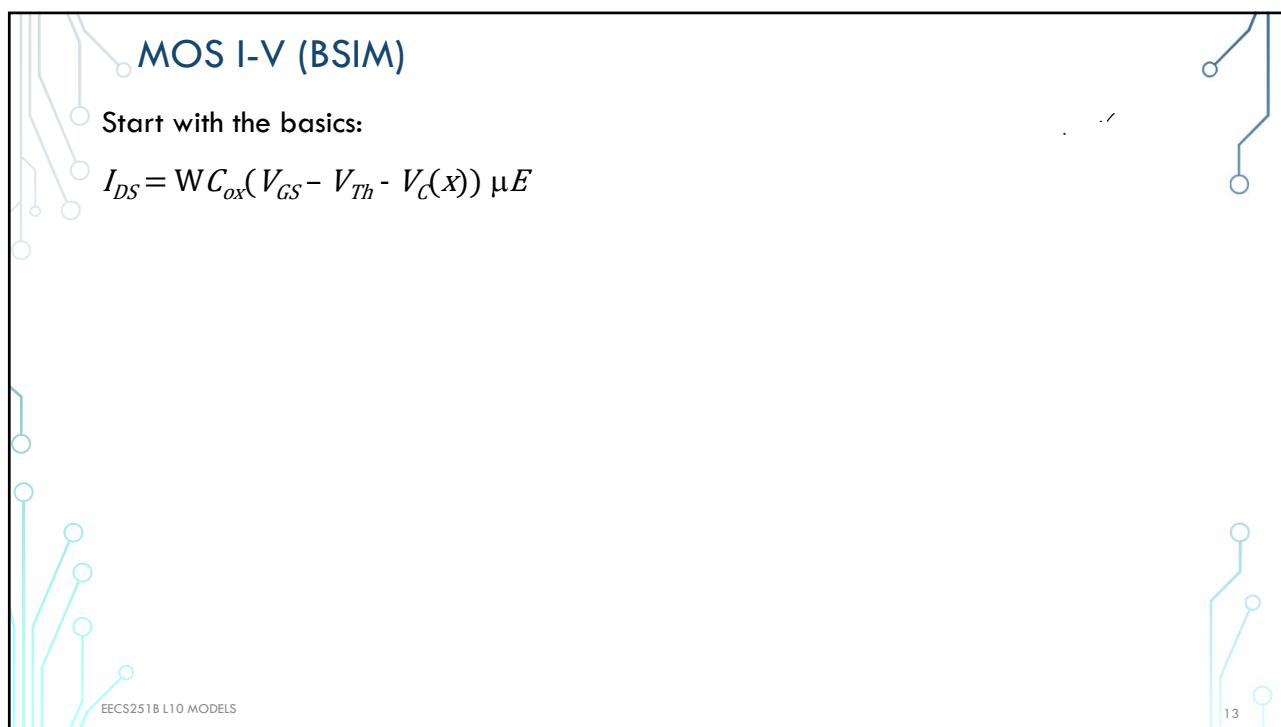
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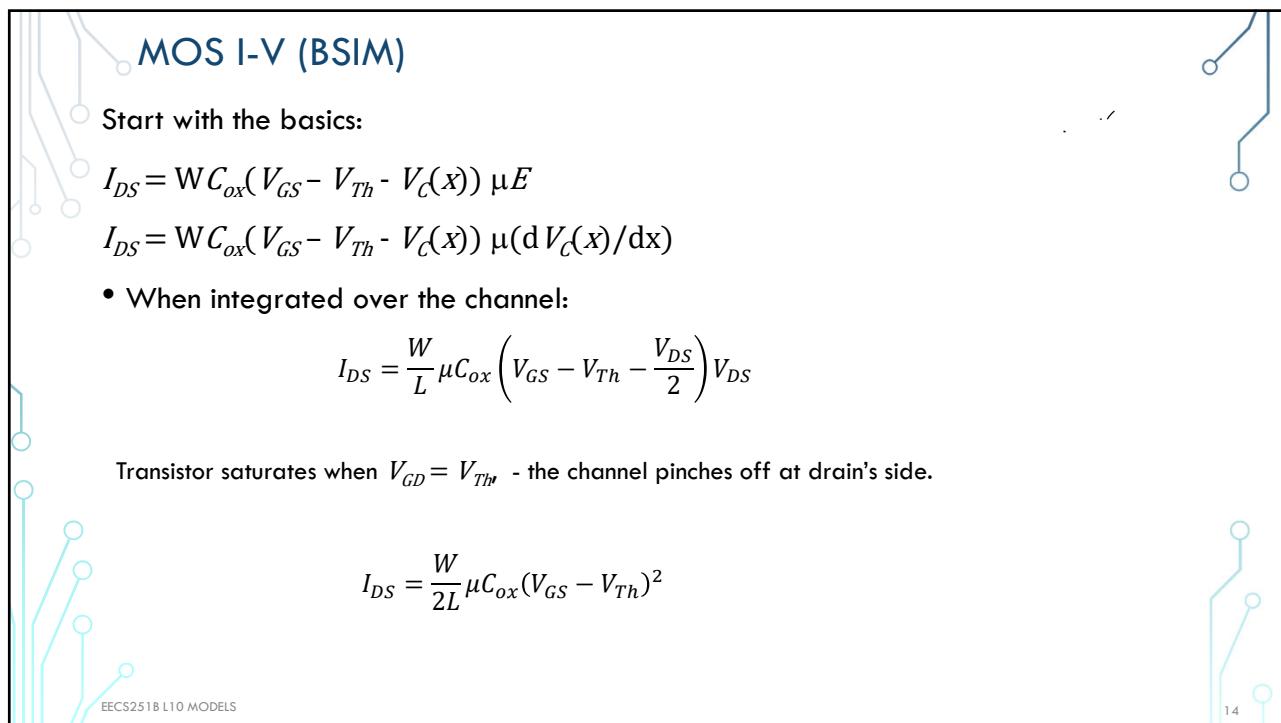
Long-Channel MOS On-Current

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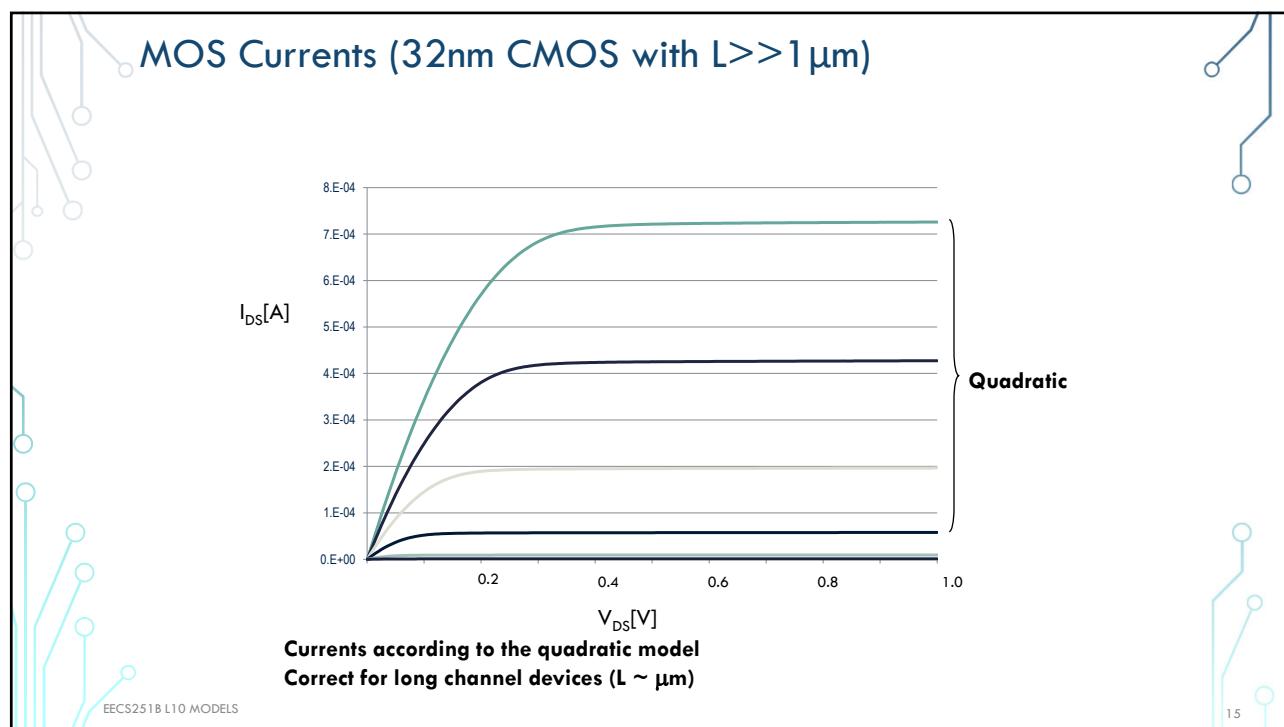
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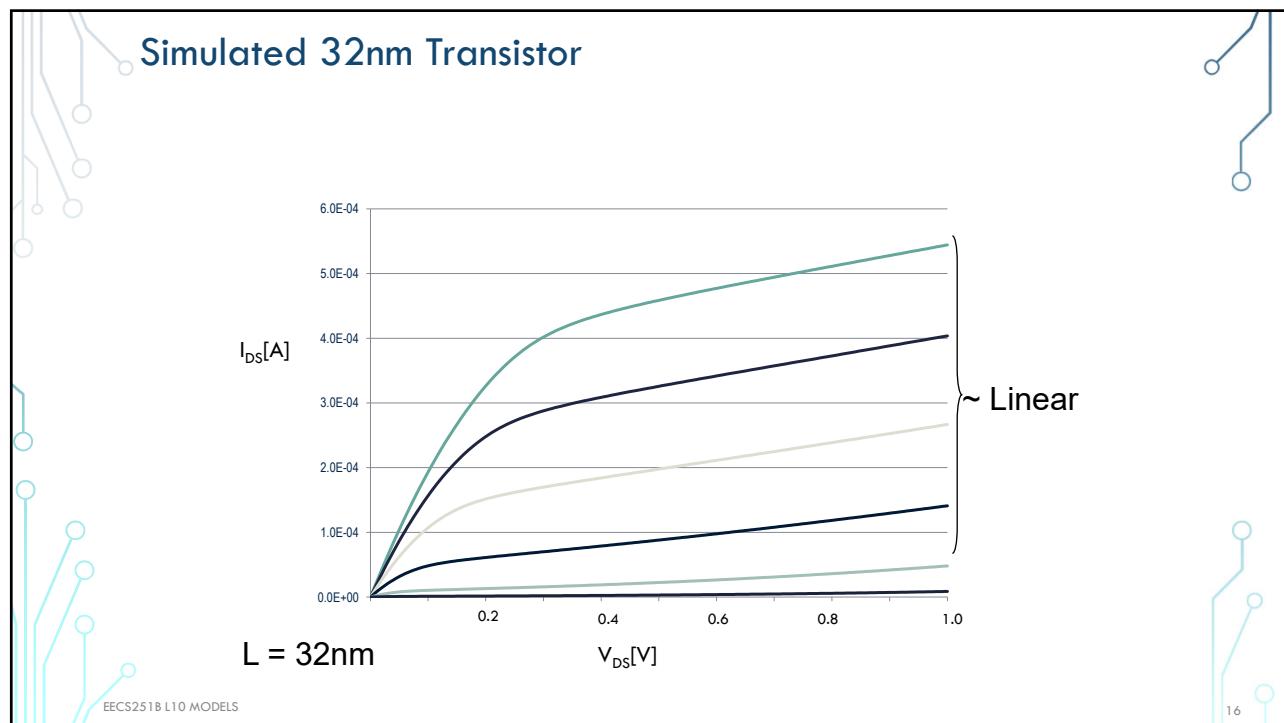
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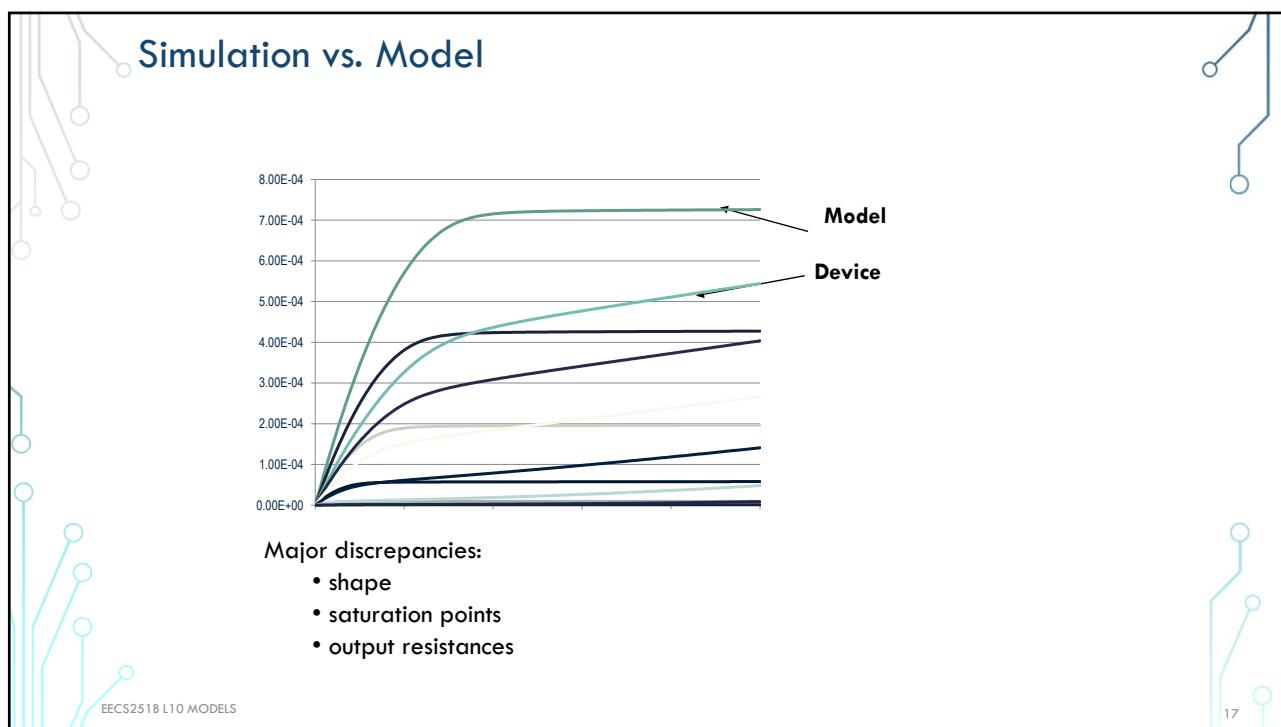
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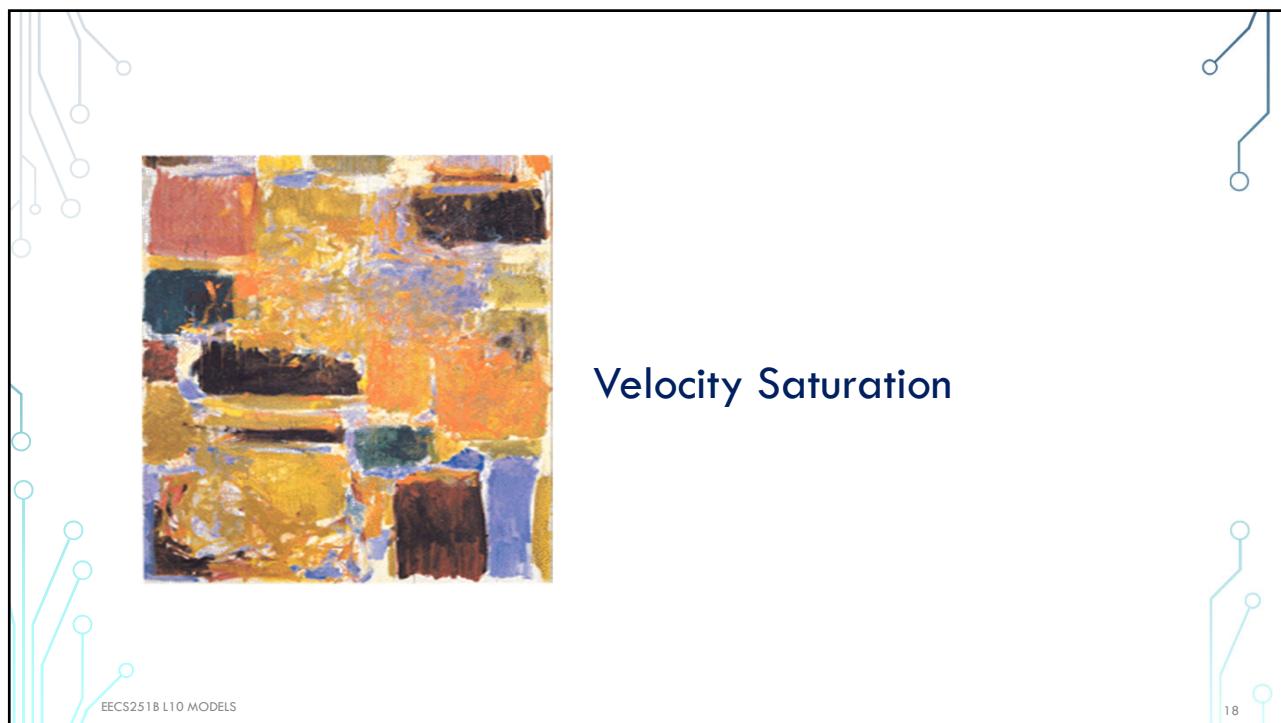
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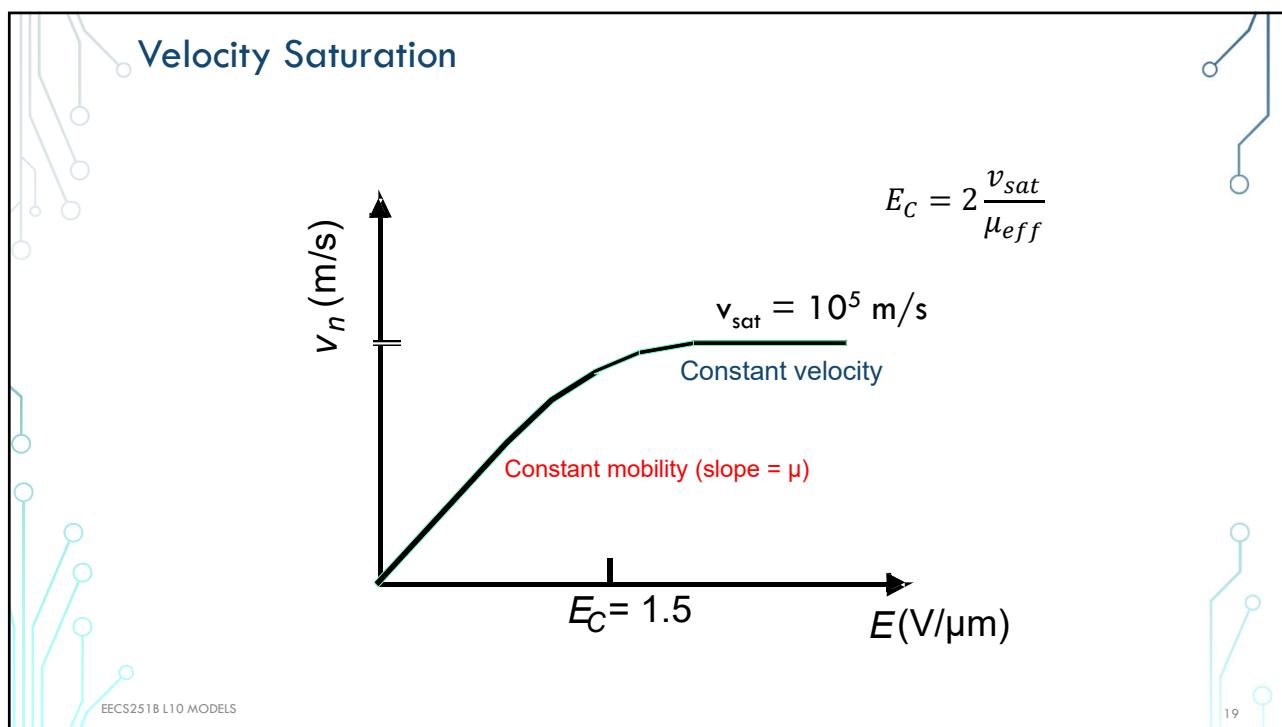
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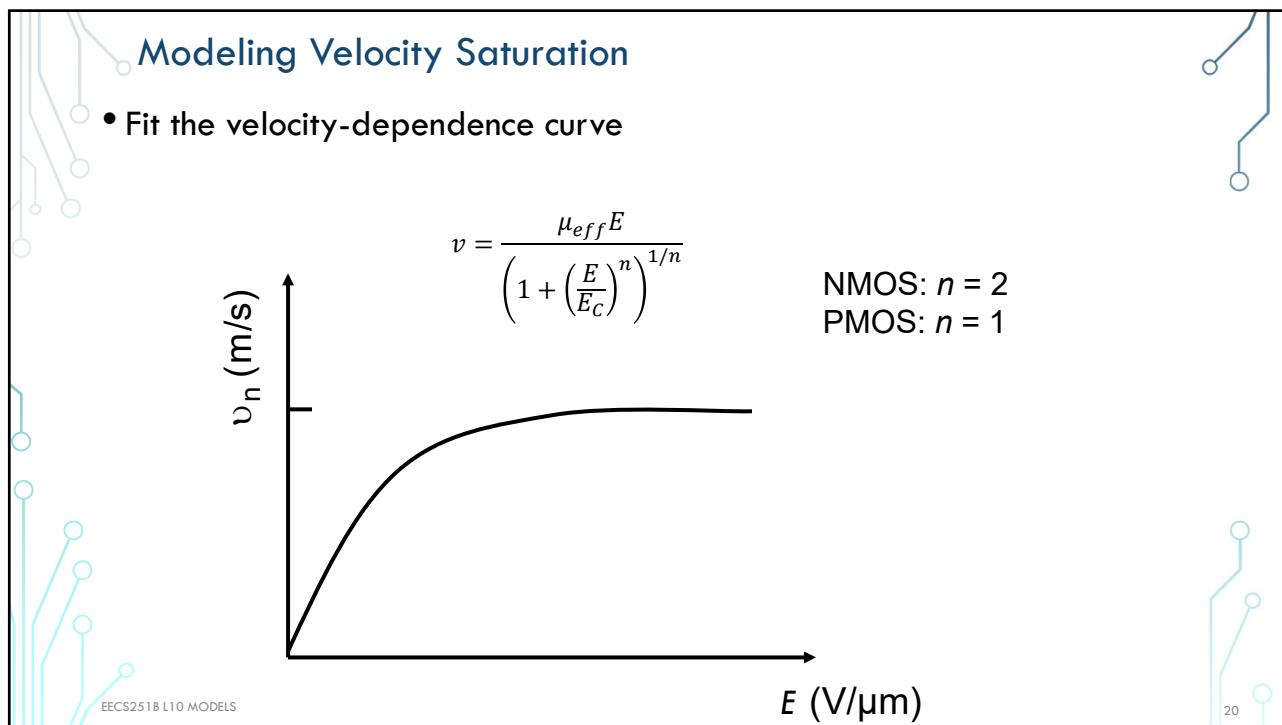
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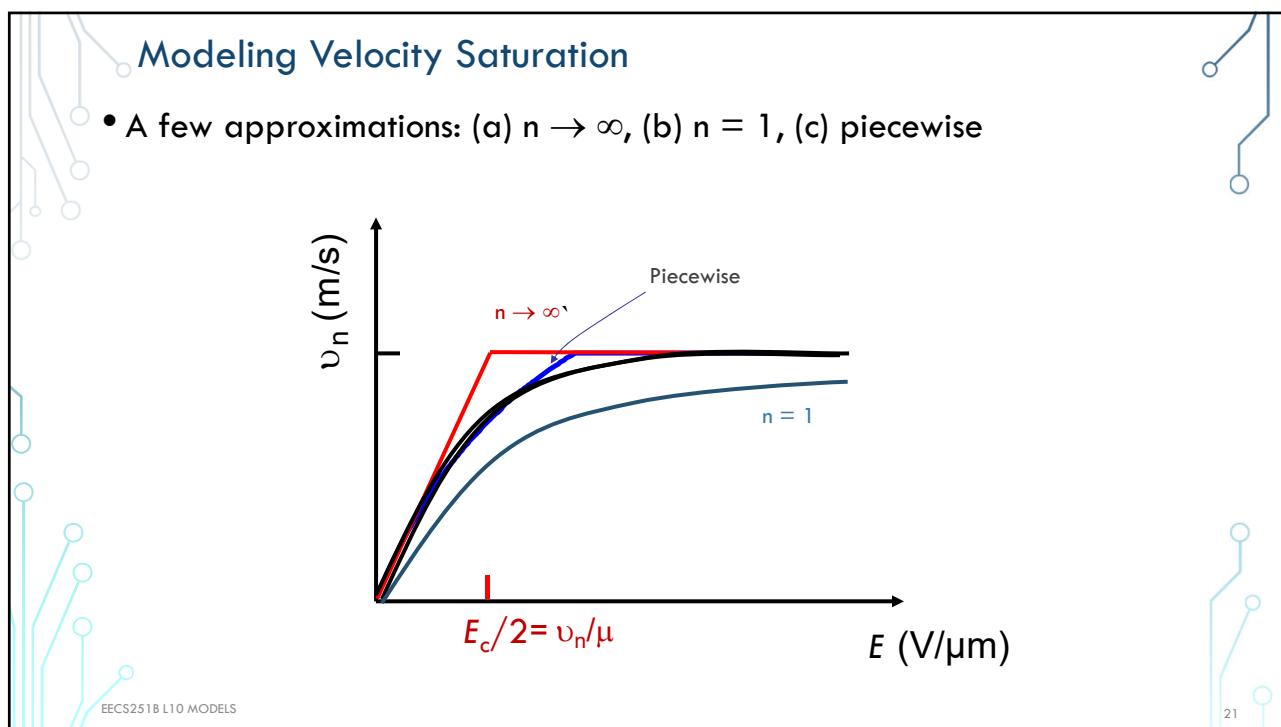
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Approximation $n \rightarrow \infty$

1) $V = \mu_{eff}E, E < E_c$ $I_{DS} = \mu C_{ox} \frac{W}{L} \left((V_{GS} - V_{Th})V_{DS} - \frac{V_{DS}^2}{2} \right)$

2) $V = V_{sat}, E > E_c$ $I_{DSat} = \mu C_{ox} \frac{W}{L} \left((V_{GS} - V_{Th})V_{DSat} - \frac{V_{DSat}^2}{2} \right)$

$V_{DSat} = ?$

Can be reduced to Rabaey DIC model by making $V_{DSat} = \text{const}$

Is this physically justified?

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MOS Model from DIC, 2nd ed.

$I_D = 0 \text{ for } V_{GT} \leq 0$

$I_D = k' \frac{W}{L} \left(V_{GT} V_{min} - \frac{V_{min}^2}{2} \right) (1 + \lambda V_{DS}) \text{ for } V_{GT} \geq 0$

with $V_{min} = \min(V_{GT}, V_{DS}, V_{DSAT})$,

$V_{GT} = V_{GS} - V_T$,

and $V_T = V_{T0} + \gamma(\sqrt{|-2\phi_F + V_{SB}|} - \sqrt{|-2\phi_F|})$

γ - body effect parameter

From Rabaey, 2nd ed.

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Unified MOS Model

- Model presented is compact and suitable for hand analysis.
- Still have to keep in mind the main approximation: that V_{DSat} is constant .
When is it going to cause largest errors?
 - When does E scale? – Transistor stacks.
- But the model still works fairly well.
 - Except for stacks

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Approximation $n = 1$, piecewise

- $n = 1$ is solvable, piecewise closely approximates

Velocity, v :

$$v = \begin{cases} \frac{\mu_{eff}E}{1 + E/E_C}, & E < E_C = \frac{2v_{sat}}{\mu_{eff}} \\ v_{sat}, & E > E_C \end{cases}$$

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Sodini, Ko, Moll, TED'84
 Toh, Ko, Meyer, JSSC'88
 BSIM model

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Drain Current

- We can find the drain current by integrating I_{DS}

$$I_{DS} = W C_{ox} (V_{GS} - V_{Th} - V_C(x)) V$$

Linear:

$$I_{DS} = \frac{\mu C_{ox}}{1 + (V_{DS}/E_C L)} \frac{W}{L} \left((V_{GS} - V_{Th}) V_{DS} - \frac{V_{DS}^2}{2} \right)$$

In saturation:

$$I_{DSat} = C_{ox} W v_{sat} (V_{GS} - V_{Th} - V_{DSat})$$

$$I_{DSat} = \frac{\mu C_{ox}}{1 + (V_{DSat}/E_C L)} \frac{W}{L} \left((V_{GS} - V_{Th}) V_{DSat} - \frac{V_{DSat}^2}{2} \right)$$

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Drain Current in Velocity Saturation

- Solving for V_{DSat}

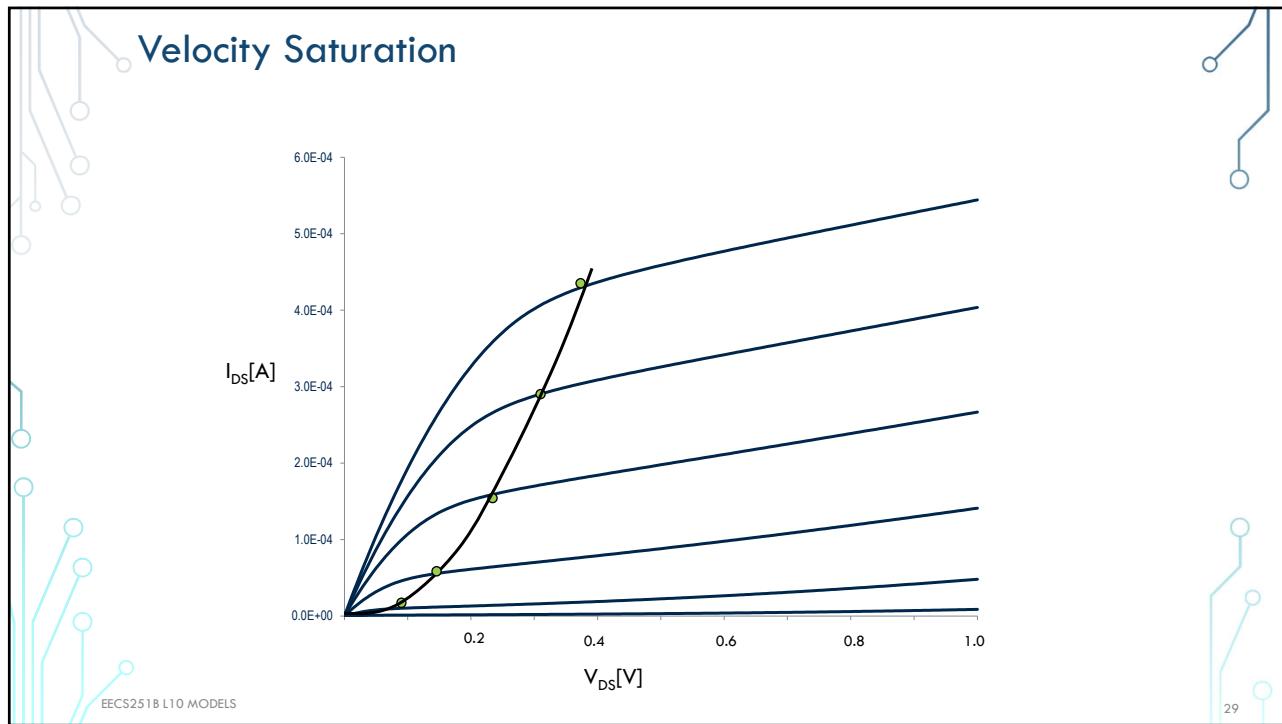
$$V_{DSat} = \frac{(V_{GS} - V_{Th}) E_C L}{(V_{GS} - V_{Th}) + E_C L}$$

And saturation current

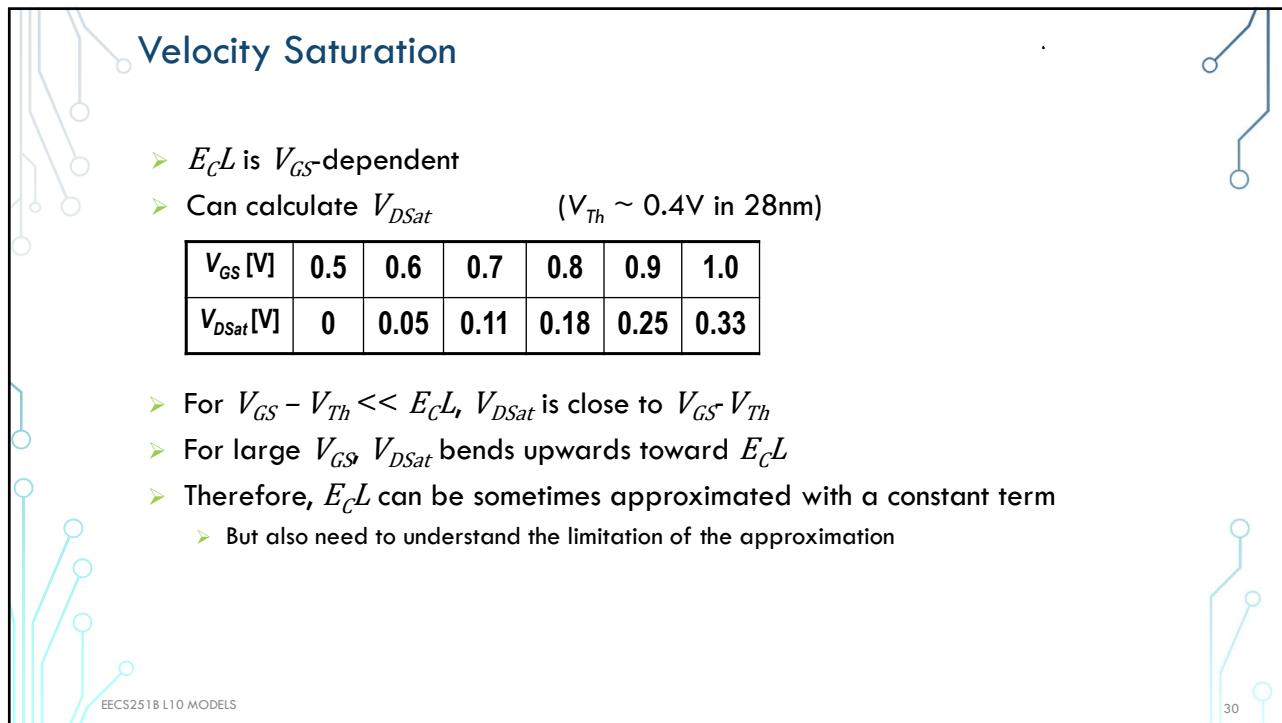
$$I_{DSat} = \frac{W \mu_{eff} C_{ox} E_C L}{2} \frac{(V_{GS} - V_{Th})^2}{(V_{GS} - V_{Th}) + E_C L}$$

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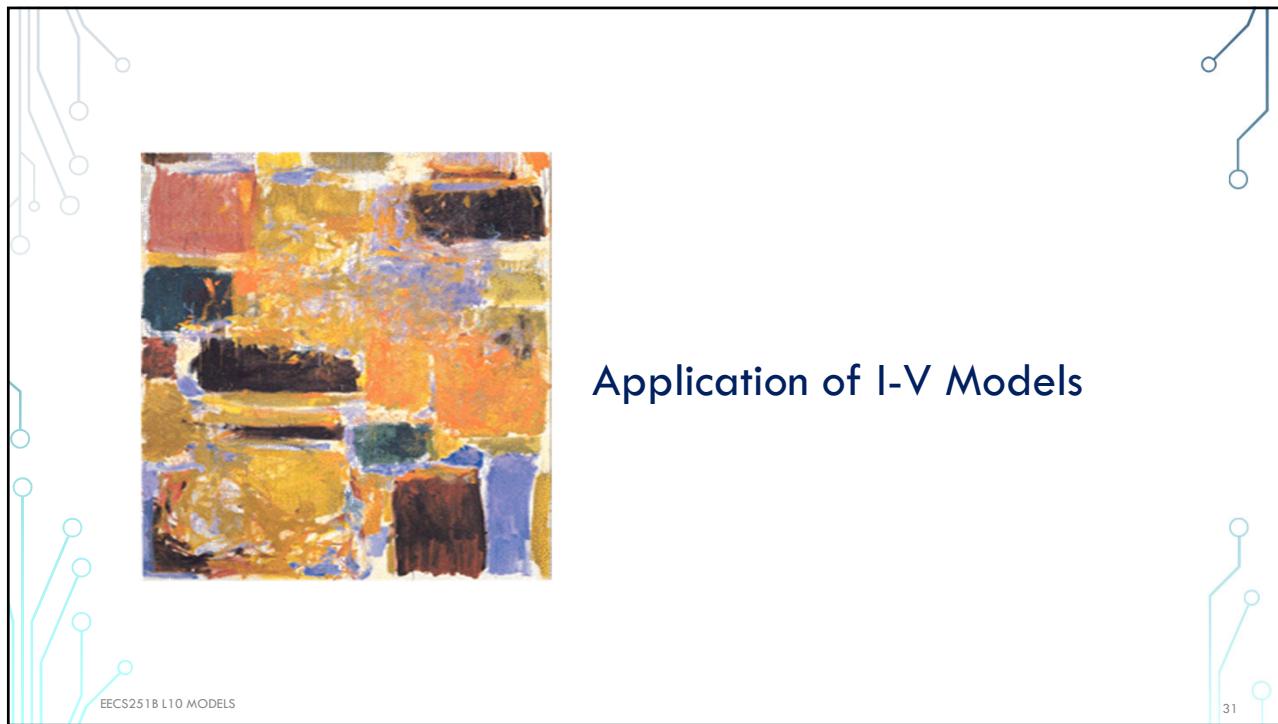
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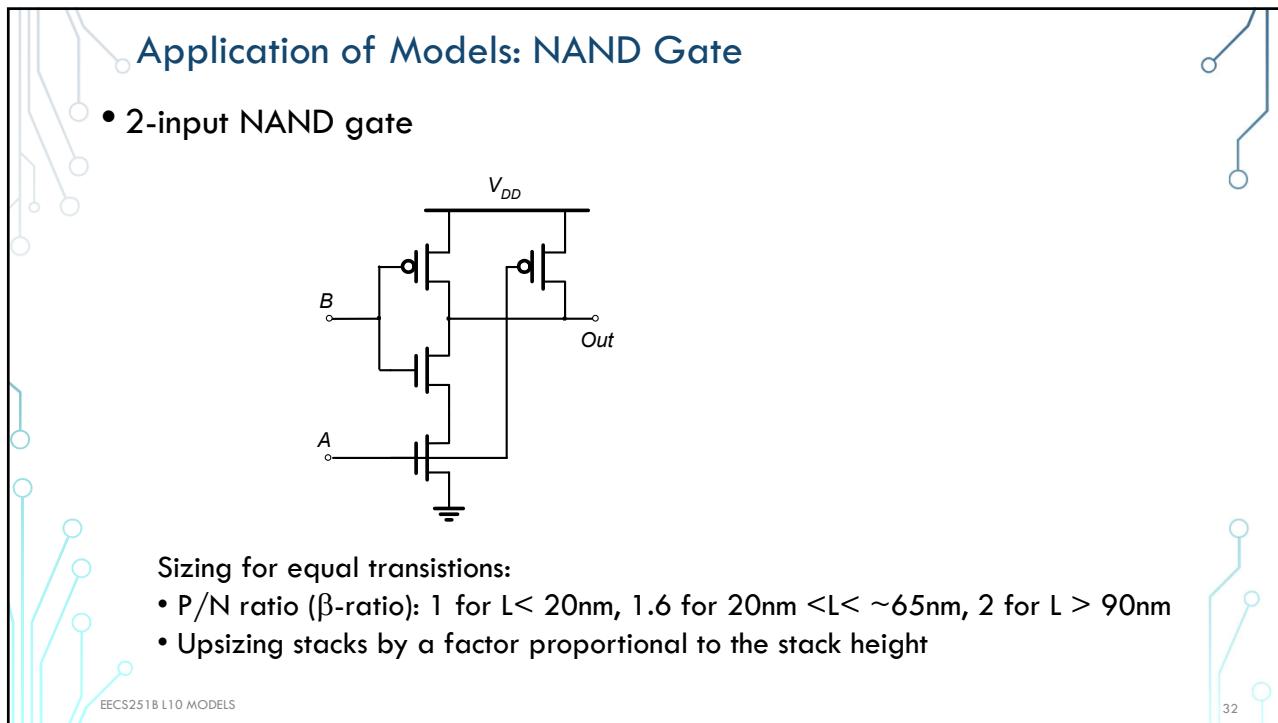


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Application of I-V Models



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Transistor Stacks

- With transistor stacks, V_{DS} , V_{GS} reduce.
- Unified model assumes $V_{DSat} = \text{const.}$
- For a stack of two, appears that both have exactly double R_{ekv} of an inverter with the same width
- Therefore, doubling the size of each, should make the pull-down R equivalent to an inverter

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Velocity Saturation

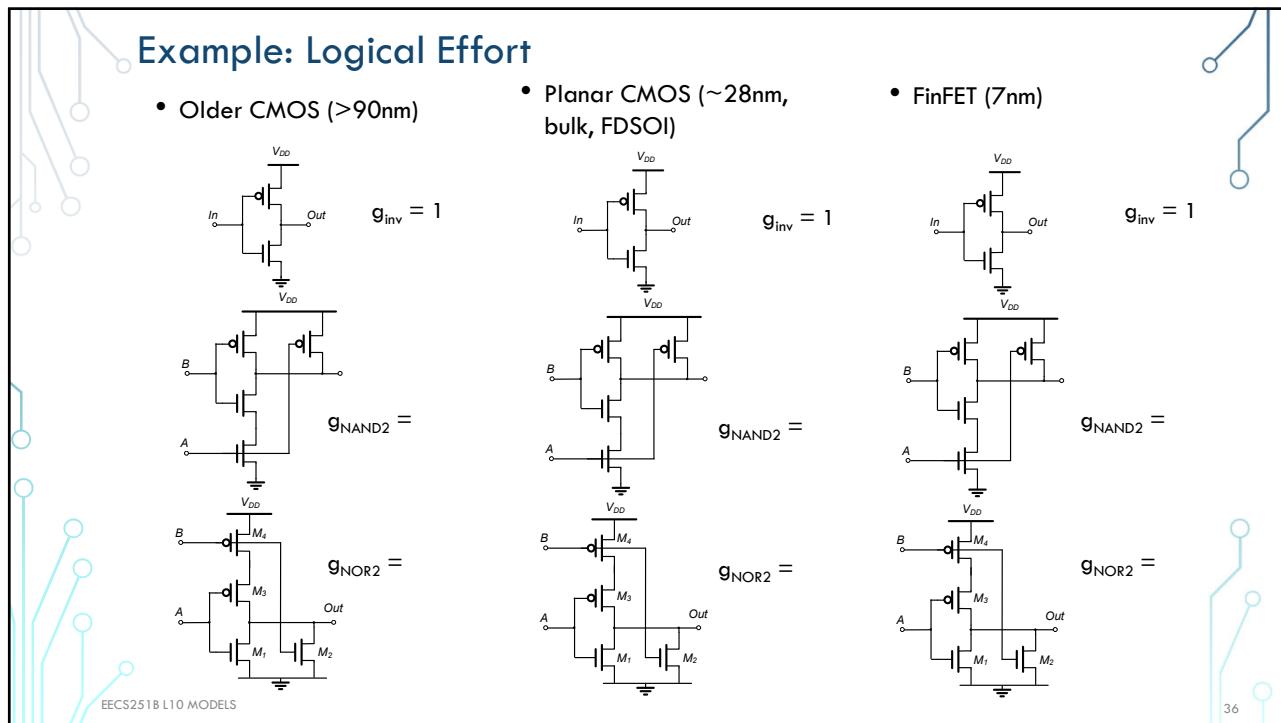
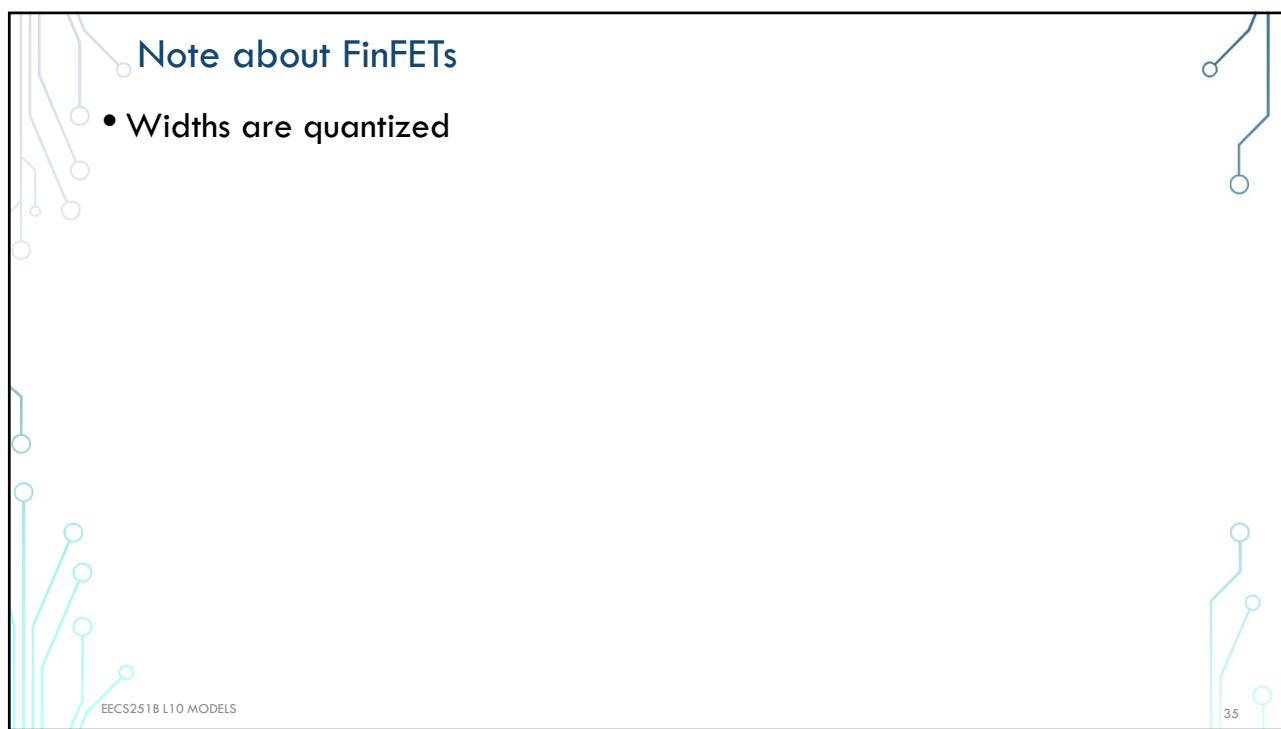
- As $(V_{GS} - V_{Th})/E_C L$ changes, the depth of saturation changes

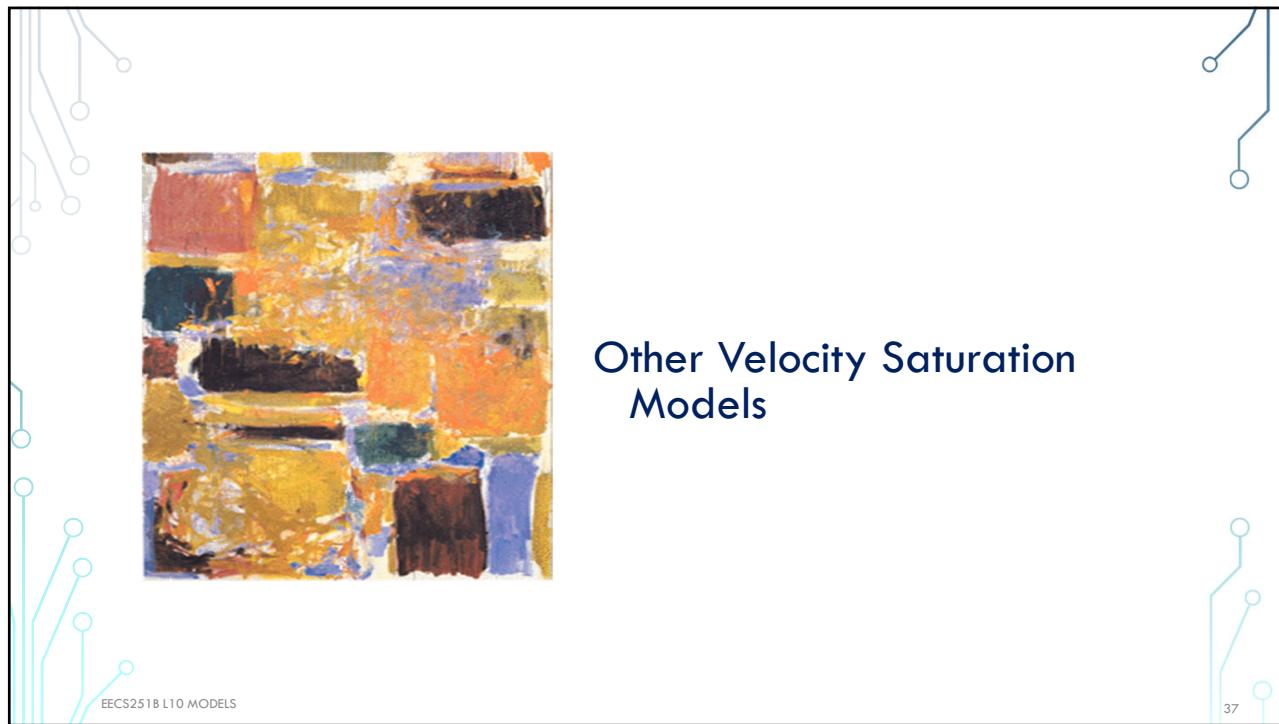
$$I_{DSat} = \frac{W}{L} \frac{\mu_{eff} C_{ox} E_C L}{2} \frac{(V_{GS} - V_{Th})^2}{(V_{GS} - V_{Th}) + E_C L}$$

- For V_{GS} , $V_{DS} = 1.0V$, $E_C L$ is $\sim 0.75V$
- With double length, $E_C L$ is $1.5V$ (in this model in 28nm)
- Stacked transistors are less saturated
- $V_{GS} - V_{Th} = 0.6V$, $I_{DSat} \sim 2/3$ of inverter I_{DSat} (64%)
- Therefore NAND2 should have pull-down sized 1.5X
- Check any library NAND2's
- Current halved in a stack of 3

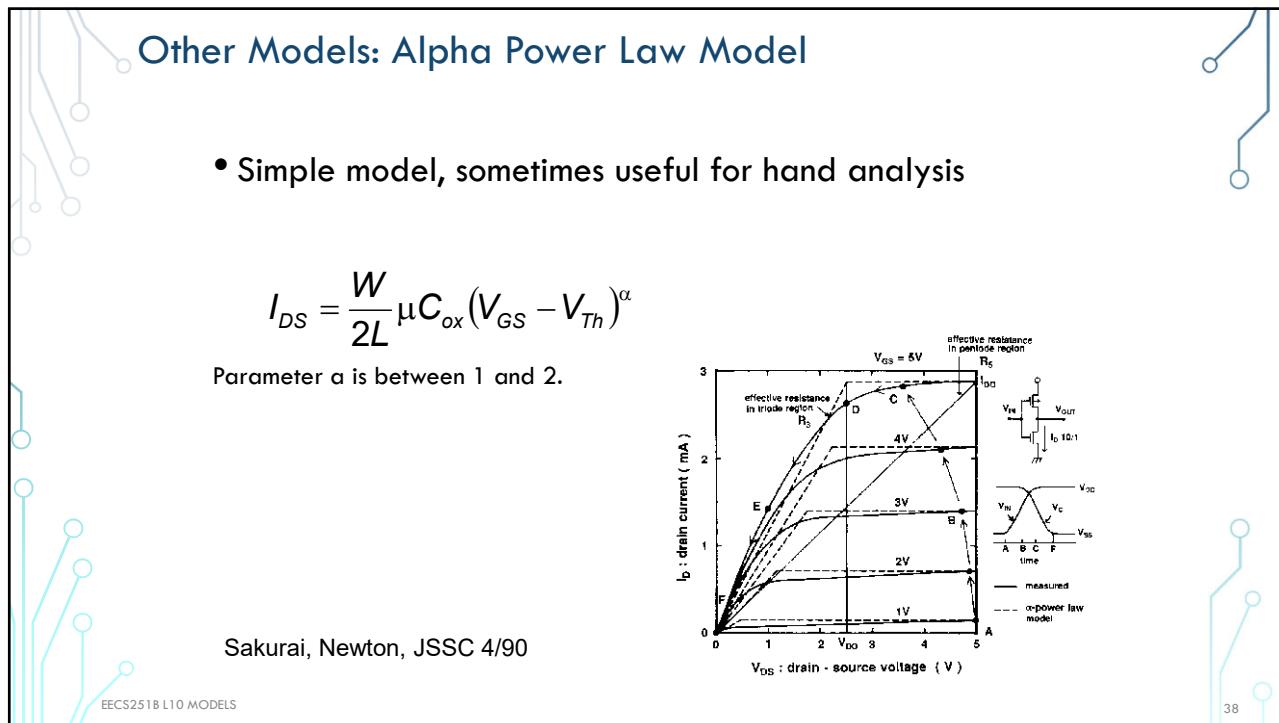
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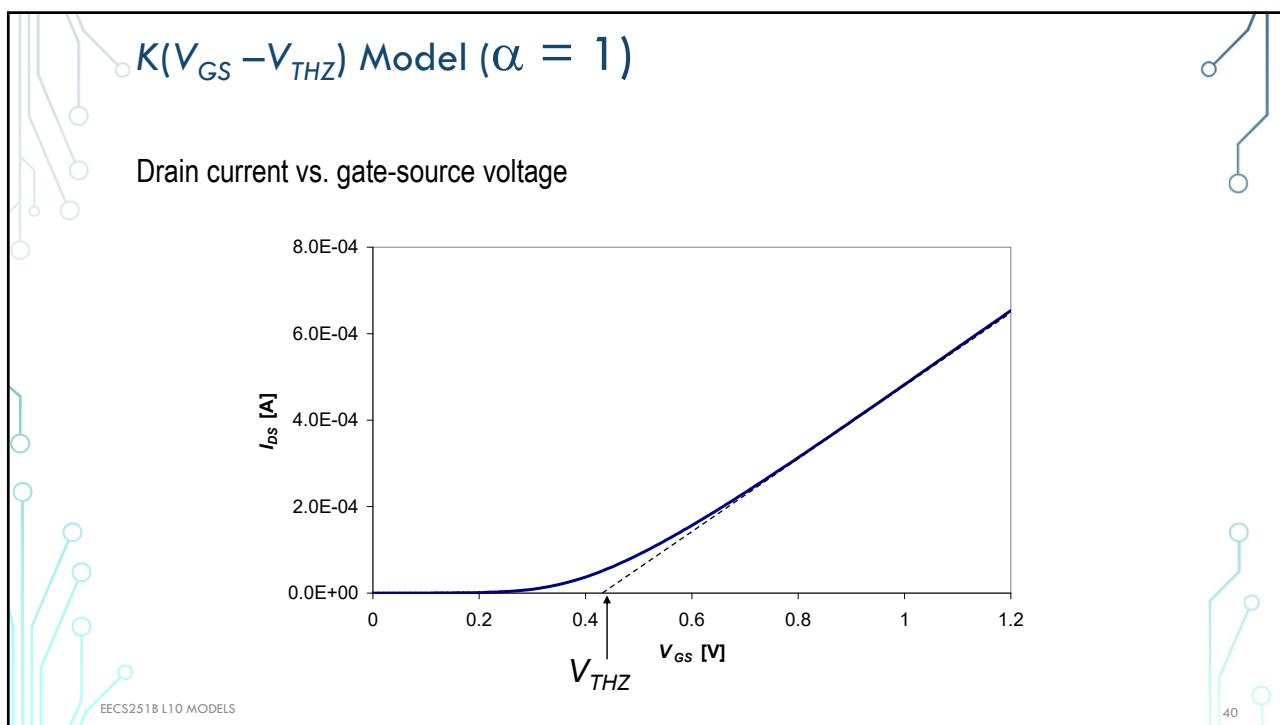
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Alpha Power Law Model

- This is not a physical model
- Simply empirical:
 - Can fit (in minimum mean squares sense) to variety of α 's, V_{Th}
 - Need to find one with minimum square error – fitted V_{Th} can be different from physical
 - Can also fit to $\alpha = 1$
 - What is V_{Th} ?

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Model	Usage
$I_{DS} = K \frac{W}{L} (V_{GS} - V_{TH})$	Delay estimates with $V_{DD} \gg V_{TH}$
$I_{DS} = \frac{W \mu C_{ox}}{L} \frac{(V_{GS} - V_{TH})^2}{2}$	Long channel devices (rare in digital)
$I_{DS} = \frac{W \mu C_{ox}}{L} \frac{(V_{GS} - V_{TH})^\alpha}{2}$	Delay estimates in a wider range of V_{DD} 's
$I_{DS} = \frac{W}{L} \mu C_{ox} \left((V_{GS} - V_{TH}) V_{Dsat} - \frac{V_{Dsat}^2}{2} \right)$	Easy to remember, does not handle stacks correctly
$I_{DS} = \frac{W \mu C_{ox}}{L} \frac{E_C L (V_{GS} - V_{TH})^2}{(V_{GS} - V_{TH}) + E_C L}$	Handles stacks correctly, sizing

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Next Lecture
• Delay models

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